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# MICRO-CAVITY FLUIDIC DYE LASER

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## ABSTRACT

We have successfully designed, fabricated and characterized a micro-cavity fluidic dye laser with metallic mirrors, which can be integrated with polymer based lab-on-a-chip microsystems without further processing steps. A simple rate-equation model is used to predict the average pumping power threshold for lasing as function of cavity-mirror reflectance, laser dye concentration and cavity length. The laser device is characterized using the laser dye Rhodamine 6G dissolved in ethanol. Lasing is observed, and the influence of dye concentration is investigated.

## INTRODUCTION

Liquid dye lasers [1] have been widely used as tunable, coherent light sources for spectroscopic analysis in the visible wavelength region - from app. 400 nm to 900 nm. In this paper we report on the design and realization of a miniaturized liquid dye laser - a micro-cavity fluidic dye laser - which can be integrated with lab-on-a-chip microsystems.

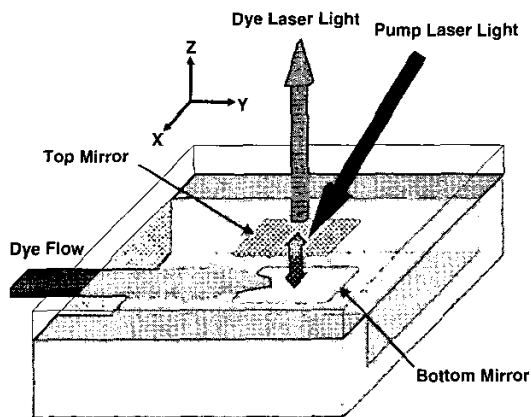


Figure 1: Vertically emitting micro-cavity fluidic dye laser. A liquid laser dye is pumped through a microfluidic channel, fitted with integrated mirrors forming the laser cavity. The dye is optically pumped by an external laser. Dye laser light is emitted through the glass lid.

The micro-fluidic dye laser consists of a micro-fluidic channel fitted with mirrors, forming the laser cavity. The laser dye is pumped through the micro-fluidic channel

by means of an external pump, and the dye laser is optically pumped by an external laser. Dye laser output is emitted vertically from the device, as illustrated in figure 1. In our design, the micro-fluidic channel structure is defined in a layer of photo-definable polymer (SU-8, [2]), sandwiched between two pyrex glass wafers. A Fabry-Perot laser cavity is formed by metallic mirrors, deposited on the top and bottom glass wafers by means of UV-lithography, e-beam evaporation and lift-off.

## DESIGN

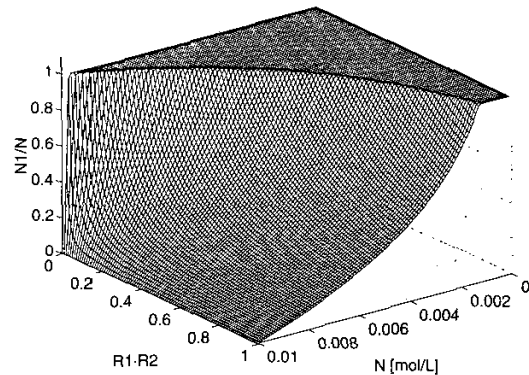


Figure 2: Surface plot of the critical inversion ratio  $N_1/N$ , which is the ratio between the concentration  $N_1$  of the excited dye molecules, and  $N$ , the concentration of Rhodamine 6G dissolved in ethanol. The data are calculated for a cavity length,  $L = 10 \mu\text{m}$ .  $N_1/N$  depends on the dye concentration  $N$  and on the product  $R_1 \cdot R_2$  of the mirror reflectances. Lasing is only possible when  $N_1/N \leq 1$ , i.e. on the curved part of the surface. As seen on the plot, lasing is not possible for dye concentrations below  $2 \cdot 10^{-3} \text{ mol/L}$ .

The first design parameter, we consider, is the height,  $H$  of the micro-fluidic channel. This is equal to the cavity length,  $L_{\text{cavity}}$ , which influences the optical modes and the round-trip gain in the laser cavity. Furthermore, it will also partly determine the optical stability of the resonator and the pressure drop across the micro-fluidic channel.

The round-trip gain can be calculated from rate equations [3]. The critical inversion ratio,  $N_1/N$ , is the ratio between the concentration of excited molecules,  $N_1$ , and the dye concentration,  $N$ , at lasing threshold. This

is given by [4]:

$$\frac{N_1}{N} = \frac{\sigma_0 - \frac{1}{2L_{cavity}N} \ln(R_1 R_2)}{\sigma_0 + \sigma_e + k_{ST}\tau_T(\sigma_0 - \sigma_T)} \quad (1)$$

The rate equation and parameters for laser dyes are described in references [3] and [4].  $\sigma_0$  is the cross section for absorption of laser light by the ground state of the dye molecule, the singlet state.  $\sigma_e$  is cross section for stimulated emission.  $\sigma_T$  is the cross section for absorption of laser light due to the triplet state in the dye molecule.  $L_{cavity}$  is the cavity length.  $k_{ST}$  is the inter-crossing rate from the excited singlet state to the excited triplet state, and  $\tau_T$  is the decay time from the excited triplet state to the singlet ground state. The critical inversion ratio at the lasing threshold,  $N_1/N$ , is calculated for a cavity length,  $L_{cavity} = 10 \mu\text{m}$  and Rhodamine 6G dissolved in ethanol. The data are plotted as a so-called critical inversion surface in figure 2. The parameters for Rhodamine 6G in ethanol are taken from [1, 3]. As seen in figure 2, lasing is possible in a  $10 \mu\text{m}$  long cavity for Rhodamine concentrations,  $N$ , above  $2 \cdot 10^{-3} \text{ mol/L}$  with a reasonable laser cavity reflectance,  $R_1 \cdot R_2$ . Cavity sizes much below  $10 \mu\text{m}$  will require higher dye concentrations, which will give problems with molecule to molecule stiction also called dimerization [1]. Dimer formation gives rise to extra optical losses in the laser dye.

Rhodamine 6G in ethanol fluoresces at wavelengths between 550 nm and 620 nm. Using the value for ethanol,  $n = 1.36$ , as a first estimate for the refractive index of the laser dye solution, and a cavity length of  $L_{cavity} = 10 \mu\text{m}$ , a total of 6 longitudinal cavity modes will overlap with the fluorescence spectrum.

The pressure drop  $\Delta P$  in a micro-channel with a rectangular cross-section (assuming newtonian fluids) is given by [5]:

$$\Delta P = 8 \frac{\eta(W+H)^2 L}{(WH)^3} \Phi = 8 \frac{\eta(W+H)^2 L}{(WH)^2} \bar{v} \quad (2)$$

$W$  and  $H$  are the width and the height, and  $L$  is the length of the microfluidic channel.  $\eta$  is the viscosity of the fluid.  $\Phi$  is the flowrate and  $\bar{v}$  is the flow speed. For a  $10 \mu\text{m}$  high channel the pressure will be fairly independent of the channel width,  $W$ , when this is larger than 1 mm.

The cavity mirrors are designed with dimensions much larger than the cavity length in order to avoid problems with optical instability. A square top mirror with a side length of 2 mm is chosen which also provides sufficient coverage of a 1 mm wide channel. The bottom mirror covers the entire chip. Gold mirrors with chromium for adhesion was chosen due to ease of fabrication. The layer thickness of the mirrors were designed for specific reflectances using the method of Cory et al. [6] and data from Palik [7]. The bottom mirror was designed to have maximal reflectance ( $R_1 = 0.83$ ) and the top-mirror to be semi-transparent ( $R_2 = 0.72$ ) for both pump- and dye laser light, i.e.  $R_1 \cdot R_2 = 0.6$ .

From the above considerations a cavity length of around  $10 \mu\text{m}$  and a cavity width of around 1 mm is reasonable. The flow channel length must be around 2.5 cm in order to accommodate the fluidic in- and outlet connections. These channel dimensions allows for flowrates up to around 200-300  $\mu\text{L}/\text{min}$ , if a pressure of 10 atm is considered as maximum.

## FABRICATION

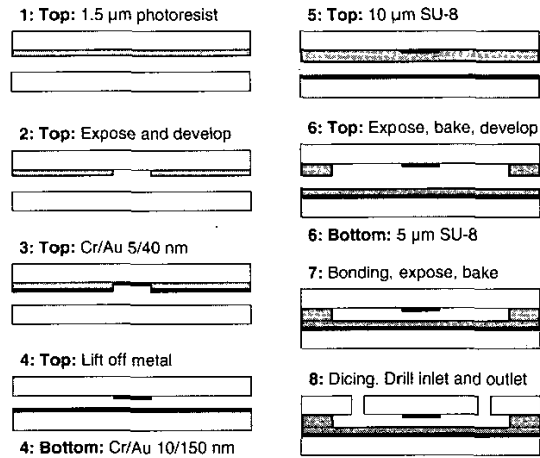


Figure 3: Fabrication process steps. 500  $\mu\text{m}$  thick Pyrex glass wafers are used as top and bottom substrates. 1-4: Metallic mirrors are deposited on the top- and bottom wafers by standard UV-lithography, electron-beam evaporation and lift-off. 5-6: The micro-flow channels are defined in SU-8 photoresist on the top wafer by spin-coating, soft-baking, UV-exposure, post exposure baking and development. A 5  $\mu\text{m}$  thick SU-8 bonding layer is deposited on the bottom wafer by spin-coating and soft-baking. 7: The wafers are bonded by a manually applied pressure at 75  $^{\circ}\text{C}$ . The wafers are further sealed by a bake at 90  $^{\circ}\text{C}$  for an hour and then cooled down before cross-linking of the SU-8 by an UV flood-exposure, followed by a post exposure bake. 8: The chips are diced and inlet/outlet holes are drilled.

The process sequence is shown in figure 3. Pyrex glass wafers are used as top and bottom wafers, and in order to simplify the process we used Cr/Au films for the mirrors. For the Cr/Au films we have calculated the reflectance  $R_1=83 \%$  (bottom),  $R_2=72 \%$  (top) and the transmittance  $T_1=0 \%$ ,  $T_2=6 \%$  [6, 7]. Our process also allows for dielectric mirrors to be used. The semitransparent top mirror is defined in a lift off process. The microfluidic channel is defined in a  $10 \mu\text{m}$  thick SU-8 photoresist. The non transparent bottom mirror is deposited on the bottom wafer and a 5  $\mu\text{m}$  thick layer of SU-8 is spun on as a bonding glue. Our low temperature SU-8 bonding technique, which was partly adapted from Jackman et al. [8] and Shen et al. [9] requires no expensive bonding equipment and yet has a good hermetic quality. Both wafers in process step 6 are heated to 75  $^{\circ}\text{C}$  and manually pressed together. The bonded wafers are baked at 90  $^{\circ}\text{C}$  for an hour. This step improved the hermetic quality of the bonding. The wafers are again exposed to UV-light in order to cross-link the

SU-8 on the bottom wafer and further cross-linked by a post exposure bake. The bonded wafers are diced before drilling inlet and outlet holes for the dye solution. A photo of a fabricated device is shown in figure 4. The channel at the center of the chip is 1 mm wide and 10  $\mu\text{m}$  high.

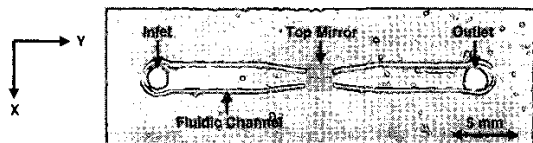


Figure 4: Photo of a glass/SU-8 chip with a micro-cavity fluidic dye laser, seen from above.

The chip is mounted in a plexiglass holder constructed with o-ring sealed fluid connections between the microfluidic channel and hoses to the external fluidic handling apparatus, as illustrated in figure 5.

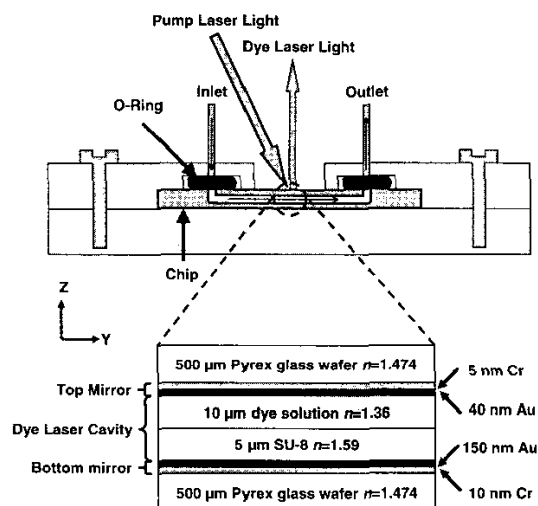


Figure 5: The micro-cavity fluidic dye laser chip is mounted in a plexiglass holder with o-ring sealed fluidic connections. The laser dye is pumped through the chip by means of an external syringe pump. The zoom-in shows a cross section of the laser cavity with the relevant layer thicknesses and refractive indices,  $n$ .

## RESULTS

The laser was characterized using the laser dye Rhodamine 6G dissolved in ethanol as active medium. The micro-cavity fluidic dye laser was pumped optically by a pulsed, frequency doubled Nd:YAG laser (wavelength 532 nm). The spot diameter of the pumping laser beam on the micro-cavity fluidic dye laser cavity was approximately 1.5 mm. The dye laser output, emitted through the semi-transparent top mirror was collected with an optical fiber coupled to a spectrometer.

The influence of the dye concentration was investigated using six different dye concentrations ranging

from  $10^{-4}$  to  $10^{-1}$  mol/L. The lowest concentration for which lasing was observed was  $10^{-2}$  mol/L. Figure 6 shows a series of 5 optical spectra from the micro-cavity fluidic dye laser, using a dye solution of  $5 \cdot 10^{-2}$  mol/L Rhodamine 6G in ethanol and a flow rate of  $10 \mu\text{L}/\text{min}$ . The first peak, at 532 nm is due to scattered light from the pumping laser. The fluorescence from the Rhodamine 6G is seen in the wavelength range from app. 550 nm to 620 nm. A strong peak around a wavelength of 578 nm emerges from the fluorescence, as the average pumping power is raised above 3 mW. The insert compares three similar spectra, recorded with different laser dye concentrations. The strong peak is shifted towards longer wavelength for increasing dye concentration.

Figure 7 shows the corresponding peak average output power versus average pumping power for the three different dye concentration. For all three dye concentrations we observe a knee in the output versus input power trace. The knee, marked by a vertical arrow, is interpreted as the onset of lasing, and the corresponding values for the pumping power threshold for lasing  $P_{\text{meas}}$  are tabulated in table 1.

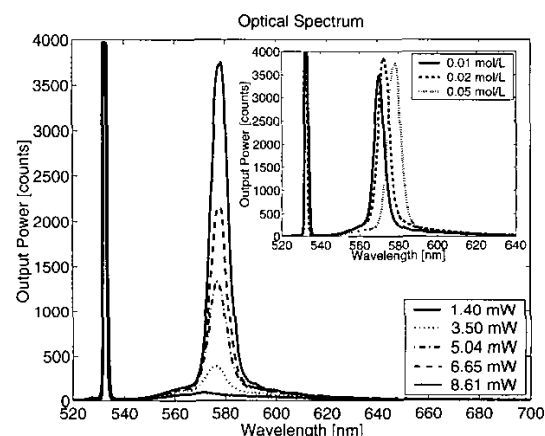


Figure 6: Measured spectra emitted from the micro-cavity fluidic dye laser, using a dye solution of  $5 \cdot 10^{-2}$  mol/L Rhodamine 6G in ethanol and a flow rate of  $10 \mu\text{L}/\text{min}$ . The spectra are recorded with different levels of optical pumping power (average power). The first peak at 532 nm is due to scattered pump laser light. A strong peak from the dye laser appears at around a wavelength of 578 nm. The insert shows three dye laser spectra for three dye concentrations  $10^{-2}$ ,  $2 \cdot 10^{-2}$ , and  $5 \cdot 10^{-2}$  mol/L. The lasing peak wavelength is shifted towards longer wavelength for increasing dye concentration. The peak wavelength for the three spectra are: 570 nm, 572 nm, and 578 nm, respectively.

## DISCUSSION

The measured threshold average pumping powers,  $P_{\text{meas}}$ , are compared to the simple rate equation model presented previously. The pump laser is pulsed with a pulse length of 5 ns and a repetition rate of 10 Hz. This is far from the stationary situation assumed in the model. However, the lifetime of the lasing photons in the cavity is in the range of 0.1 ps for our parameters

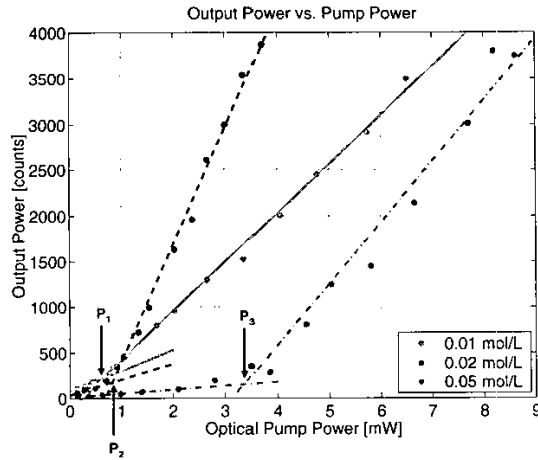


Figure 7: Measured lasing peak average output power versus average pumping power for the three dye concentrations  $10^{-2}$ ,  $2 \cdot 10^{-2}$ , and  $5 \cdot 10^{-2}$  mol/L. Each trace exhibits a knee, which is interpreted as the onset of lasing. In order to extract a value for the threshold pumping power,  $P_1$  (indicated on the plot), straight lines are fitted to the two parts of each trace. The extracted values are:  $P_1 = 0.6$  mW,  $P_2 = 0.8$  mW, and  $P_3 = 3.4$  mW.

[3]. This is much shorter than the laser pulse length, and the model is used as an approximation. The calculated critical inversion population  $N_1$ , which can be found from equation 1, can be used for calculating the corresponding threshold average pumping power  $P_{inv}$ . The following expression is obtained following Schäfer [1]:

$$P_{inv} = \frac{N_1 hc L_{cavity} A}{P_{conv} T \lambda_p \tau_0} \quad (3)$$

$hc/\lambda_p$  is the pumping photon energy.  $L_{cavity}$  is cavity length and  $A$  is the area of excitation on the dye laser cavity.  $\tau_0$  is the fluorescent lifetime.  $T$  is a constant, due to the reduced transmittance of the pumping light through the top mirror. For this case  $T = 0.07$ .  $P_{conv}$  is a conversion factor from peak power to average power and is for our Nd:YAG laser approximately  $20 \cdot 10^6$ .

Table 1 shows the comparison between the measured average threshold pump power and the average threshold pump power predicted by the model for different dye concentrations. Due to the short pulsed pumping the

$N$ [mol/L]	$10^{-2}$	$2 \cdot 10^{-2}$	$5 \cdot 10^{-2}$	$10^{-1}$
$P_{meas}$ [mW]	0.6	0.8	3.4	8.6
$P_{model}$ [mW]	0.96	0.96	0.97	0.98

Table 1: Comparison between measured average threshold pump power and the average threshold pump power predicted by the model for the critical inversion ratio for different concentrations. There is an agreement at lower concentrations but at higher concentrations the measured threshold exceeds the predicted values. This could be an indication of dimerization of the dye molecules due to the high concentrations. The model does not take dimerization into account.

triplet state can be ignored, which has been done for the

calculated values in table 1.

There is a good agreement between the measured values and the model for the lower concentrations. However, at higher concentrations there is a large deviation. The measured values at high concentration are much higher than values predicted by the model. This can be an indication of dimerization due to the high dye concentrations. Dimerization is not accounted for in the model.

In conclusion, we have demonstrated a micro-cavity fluidic dye laser, fabricated by standard micro-fabrication techniques. The laser can easily be integrated with lab-on-a-chip microsystems. A simple rate equation model was used in the design considerations. The model shows, that lasing can be achieved in a  $10 \mu\text{m}$  long cavity at moderate concentrations of the laser dye Rhodamine 6G in ethanol. The model also predicts, that lasing is obtainable with low cavity mirror reflectance and for reasonable dye concentrations.

In our design, the laser dye is continuously pumped through the laser cavity. This allows for cw laser operation and a long lifetime for the system. Other groups have previously demonstrated micro-cavity dye lasers [10, 11], but to our knowledge, our design is the first one using standard micro-fabrication techniques for fluidic dye lasers.

## ACKNOWLEDGEMENTS

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